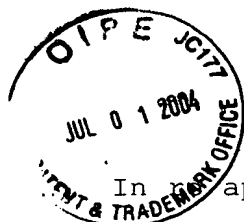


IFW



PATENT  
8017-1096

IN THE U.S. PATENT AND TRADEMARK OFFICE

In re application of

Yasuaki TSUCHIYA et al.

Conf. 4719

Application No. 10/622,735

Group 1755

Filed July 21, 2003

SLURRY FOR POLISHING COPPER-BASED  
METAL

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

July 1, 2004

Sir:

In compliance with Rules 1.97 and 1.98, and in fulfillment of the duty of disclosure under Rule 1.56, the accompanying documents, copies of which are attached to this statement, are made of record on the enclosed Form PTO-1449.

A concise explanation of the relevance of these items is that these references were cited by the Taiwanese Patent Office in an Official Action (U.S. Patent No. 6,171,352 is the U.S. counterpart for Taiwanese Patent 455626). A copy of the Taiwanese Official Action in which they were cited is attached hereto. **An English translation of the Taiwanese Official Action is also attached hereto.**

Respectfully submitted,

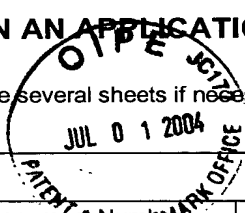
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**INFORMATION DISCLOSURE CITATION  
IN AN APPLICATION**

(Use several sheets if necessary)


 Attorney Docket No.:  
**8017-1096**

 Application No.:  
**10/622,735**

 Applicant:  
**Yasuaki TSUCHIYA et al.**

 Filing Date:  
**July 21, 2003**

 Group Art Unit:  
**1755**
**U.S. PATENT DOCUMENTS**

Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing date (if appropriate)
	6,171,352	1/9/2001	LEE et al.			

**FOREIGN PATENT DOCUMENTS**

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation	
						Yes	No
	455626	09/21/2001	TAIWAN				

**OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)**


EXAMINER:

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

\* Abstract provided for the Examiner's convenience